



OCT 02 2007

INFORMATION DISCLOSURE STATEMENT BY APPLICANT <small>1449/A and B (modified PTO/SB/08)</small>				APPLICATION NO.: 10/021,740	ATTY. DOCKET NO.: M0925.70108US00
				FILING DATE: October 22, 2001	CONFIRMATION NO.: 1110
				APPLICANT: Yet-Ming Chiang et al.	
				GROUP ART UNIT: 1745	EXAMINER: J.S. Maples
Sheet	1	of	2		

U.S. PATENT DOCUMENTS

Examiner's Initials #	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication or Issue of Cited Document MM-DD-YYYY
		Number	Kind-Code		
		4599114		Atkinson	07-08-1986
		5399447		Chaloner-Gill et al.	03-21-1995
		5405937		Lemaire et al.	04-11-1995
		5441830		Moulton et al.	08-15-1995
		5464707		Moulton et al.	11-07-1995
		5478676		Turi et al.	12-26-1995
		5520850		Chaloner-Gill et al.	05-28-1996
		5554459		Gozdz et al.	09-10-1996
		5567754		Stramel	10-22-1996
		5578396		Fauteux et al.	11-26-1996
		5587253		Gozdz et al.	12-24-1996
		5588971		Fauteux et al.	12-31-1996
		5589297		Koga et al.	12-31-1996
		5591544		Fauteux et al.	01-07-1997
		5705291		Amatucci et al.	01-06-1998
		5827615		Touhsaent et al.	10-27-1998
		5840087		Gozdz et al.	11-24-1998
		5910382		Goodenough et al.	06-08-1999
		6063519		Barker et al.	05-16-2000
		6069221		Chasser et al.	05-30-2000
		6117593		Stachoviak et al.	09-12-2000
		6287720	B1	Yamashita et al.	09-11-2001
		6291097	B1	Barker et al.	09-18-2001
		6337156	B1	Narang et al.	01-08-2002
		6358645	B1	Furukawa et al.	03-19-2002
		6403263	B1	Roach	06-11-2002
		6410189	B1	Yamada et al.	06-25-2002
		6413284	B1	Chu et al.	07-02-2002
		6413285	B1	Chu et al.	07-02-2002
		6511780	B1	Veregin et al.	01-28-2003
		6528033	B1	Barker et al.	03-04-2003
		6555268	B1	Inoue et al.	04-29-2003
		6645675	B1	Munshi	11-11-2003
		6753111	B2	Kweon et al.	06-22-2004
		6787232	B1	Chiang et al.	09-07-2004
		6797435	B2	Kweon et al.	09-28-2004
		6800399	B2	Matsumoto	10-05-2004

FORM PTO-1449/A and B (modified PTO/SB/08) INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICATION NO.: 10/021,740	ATTY. DOCKET NO.: M0925.70108US00
				FILING DATE: October 22, 2001	CONFIRMATION NO.: 1110
				APPLICANT: Yet-Ming Chiang et al.	
Sheet 2 of 2	GROUP ART UNIT: 1745	EXAMINER: J.S. Maples			

U.S. PATENT DOCUMENTS (cont.)

	6878487	B2	Cho et al.	04-12-2005
	7026071	B2	Mayes et al.	04-11-2006
	7087348	B2	Holman et al.	08-08-2006
	7090785	B2	Chiang et al.	08-15-2006
	20020071990	A1	Kweon et al.	06-13-2002
	20020071991	A1	Kweon et al.	06-13-2002
	20030003352	A1	Kweon et al.	01-02-2003
	20030008212	A1	Akashi et al.	01-09-2003
	20030049529	A1	Cho et al.	03-13-2003
	20030054250	A1	Kweon et al.	03-20-2003
	20030099884	A1	Chiang et al.	05-29-2003
	20030114297	A1	Shinn et al.	06-19-2003
	20040018429	A1	Kweon et al.	01-29-2004
	20040018430	A1	Holman et al.	01-29-2004
	20040018431	A1	Gozdz et al.	01-29-2004
	20040185343	A1	Wang et al.	09-23-2004
	20040265692	A1	Long et al.	12-30-2004
	20050026037	A1	Riley, JR. et al.	02-03-2005
	20050034993	A1	Gozdz et al.	02-17-2005

FOREIGN PATENT DOCUMENTS

Examiner's Initials #	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Translation (Y/N)
		Office/ Country	Number	Kind Code			

OTHER ART — NON PATENT LITERATURE DOCUMENTS

Examiner's Initials #	Cite No	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)
		ARBIZZANI et al, "Li1.01Mn1.974 surface modification by pol(3,4-ethylenedioxythiophene)," J. Power Sources, 119-121:695-700	
		HADZIOANNOU, et al., "Monocristaux de copolymères trisequences styrene/isoprene/styrene présentant la structure cylindrique," Colloid Poly Sci., 257:4, 413-419	
		"Defects," Unknown book chapter, p. 339-424	

EXAMINER:	DATE CONSIDERED:
-----------	------------------

[#] EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

*a copy of this reference is not provided as it was previously cited by or submitted to the office in a prior application, Serial No. ___, filed ___, and relied upon for an earlier filing date under 35 U.S.C. 120 (continuation, continuation-in-part, and divisional applications).

[NOTE – No copies of U.S. patents, published U.S. patent applications, or pending, unpublished patent applications stored in the USPTO's Image File Wrapper (IFW) system, are included. See 37 CFR §1.98 and 1287OG163. Copies of all other patent(s), publication(s), unpublished, pending U.S. patent applications, or other information listed are